

Article

Characteristics of Oxide Films on Zr702 and Their Corrosion Performance in Boiling Fluorinated Nitric Acid

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Abstract: Fluoride ions, which interfere with the oxide formation on zirconium have been overlooked until recently. The effect of fluoride ions on oxide formation and dissolution behaviors in zirconium was investigated in this study. A detailed quantitative characterization of the oxide films formed on Zr702 immersed in a fluorinated nitric acid solution was performed using X-ray photoelectron spectroscopy, high-resolution transmission electron microscopy, and representative high-angle annular dark-field scanning Transmission Electron Microscope, (TEM). The corrosion performance in a fluorinated nitric acid solution was discussed. The results reveal that the thickness of the oxide films immersed in the fluorinated nitric acid solution was between 42–48 nm, which is much thinner than that of the oxide layer (~98.85 nm thickness) in the F⁻ free HNO₃ solution. The oxide film was identified to be a nanocrystalline cluster, comprised of outermost HfO₂ and HfF₄ layers, sub-outer ZrO₂ and ZrF₄ layers, and an innermost Zr (F, O)_{3,6} layer. This fluoride species penetration through the oxide films indicated that the fluoride ions are responsible for the dissolution of the oxide film of Zr702.

Keywords: Zr702; fluoride ion; HNO₃; corrosion behavior; oxide films



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1. Introduction

Zirconium base alloy (Zr alloy) is a key material in the nuclear industry due to its thermal stability, mechanical durability, and low thermal neutron cross-section. However, corrosion can seriously affect its integrity and service life. The corrosion resistance of zirconium stems from the passive oxide films on its surface. The oxide film is most likely zirconium dioxide (ZrO₂), a compound closer to insulators than semiconductors. The chemical bonding between zirconium and oxygen is extremely strong, and as the oxide film grows, the current will flow through the film with increasing difficulty [1–5]. ZrO₂ retains most of its corrosion protection ability when its pH is less than 1 and above 13. Zirconium is one of the few metals that exhibits excellent corrosion resistance over a wide range of pH levels, and thus, it can be used in processes that cycle between strong acids and strong alkalis. However, when zirconium is placed in a nitric acid solution containing fluoride ions, its passive oxide films will start to dissolve [6–10].

Hlawka et al. reported that the dissolution rate of zirconium in hydrofluoric acid depends only on acid concentration but that the properties of the oxide film on zirconium are determined by the nature of the strong acid added to hydrogen fluoride [11]. According to the authors, extremely high corrosion rates were observed for Zr-4 coupons in a fluorinated nitric acid medium.

Zulai Li et al. [12]. investigated the corrosion behavior of industrial reactor materials Ti (TA2) and Zr (ZR-1) under acidic conditions (20 vol% H₂SO₄ or 20 vol% HNO₃ solutions). The results showed that in 20 vol% HNO₃ solution, the corrosion rate of Zr increases 120 when the solution is heated to 200 °C.

Zhang wei jia Qiu recently demonstrated the formation of a dense Na₃ZrF₇ layer on the surface of Zr₅₂Al₁₀Ni₆Cu₃₂ bulk metallic glass when it was immersed in 0.1 M NaF aqueous solutions with pH = 8.0 and that with 0.001 M NaF at pH = 4.0, the passive film dissolution rate increased due to the reduced pH [13,14]. Their study provides a deeper understanding of the corrosion mechanism of Zr-based BMG alloys in F⁻-containing solution. All these studies demonstrated that fluorine present in nitric acid drastically reduced the corrosion resistance of zirconium immersed in the acid. However, according to some other studies, zirconium and its alloys in fluoride solutions exhibit low corrosion rates only when the temperature of the solution is sufficiently low and its pH is sufficiently high [15]. Nevertheless, corrosion processes in fluoride solutions involved in these systems are controversial. B. Gwinner [16,17] estimated the change in oxide layer thickness over time by in situ electrochemical methods (electrochemical impedance spectroscopy (EIS) and coulomb analysis) and ectopic X-ray photoelectron spectroscopy (XPS) simultaneously. It was found that adding a small amount of fluorine (a few tenths of a mole per liter) to nitric acid significantly altered the corrosion process. Three stages were observed in the corrosion mechanism. They suggested that when the oxide layer on zirconium is thin, pits can appear on the layer because fluorine diffuses through the oxide, accumulates, and reacts at the zirconium/oxide interface to initiate pits. All previous studies focused on the corrosion rate and dynamics of fluorinated nitric acid [18,19]. Fluoride ions, which interfere with the oxide formation on zirconium, have been overlooked until recently. This study focused mainly on how the presence of small amounts of fluorine (a few ppm) could modify the corrosion resistance of zirconium. Fluoride ions and how to interfere with oxide formation will be discussed in this paper. Thus, in this study, the effect of fluoride ions on oxide formation and dissolution behaviors in zirconium was investigated with the aim of providing new insight into this effect. To this aim, the chemical nature of the corroded zirconium interface at the zirconium/solution interface was characterized using high-resolution transmission electron microscopy (HRTEM) and high-angle annular dark-field scanning TEM (HAADF-STEM).

2. Materials and Methods

Zr702 prepared via vacuum arc re-melting was obtained from the Northwest Institute for Non-ferrous Metal Research, Xi'an, China. The chemical composition of the alloy used in the study was 2.1 wt% Hf, 0.043 wt% Fe, 0.008 wt% Cr, 0.12 wt% O, 0.006 wt% C; 0.007 wt% N, and 0.002 wt% H, with Zr forming a balance. After their heat treatment, the Zr702 samples were cut into 30 mm × 15 mm sheets, 3 mm in thickness, using a diamond cutter to obtain Zr702 specimens. The specimens were then wet polished using 1000 grit emery paper, degreased in acetone, dried, and weighed to an accuracy of 0.0001 g. Static immersion measurements of the specimens were performed according to ASTM Standard G31-72 [19]. The experimental set-up used in the study is illustrated in Figure 1. The experimental device uses a conical flask with a conical grinding mouth to hold the corrosive medium and is equipped with a well-cooled reflux condensing tube. The conical flask and the condensing tube are assembled and put into a temperature-controlled electric heating sleeve, which uses an electric heating jacket to heat nitric acid to a slightly boiling state temperature. The Zr702 specimens were exposed for 240 h to a boiling (110 °C) and concentrated (6 M) nitric acid solution containing 0–200 ppm fluoride ions. The fluoride ions introduced into the boiling nitric acid were obtained from analytical grade sodium fluoride (NaF) salts. The specimens were thereafter removed from the nitric acid solution, and the changes in their weights were measured every 48 h. The concentration of zirconium dissolved in the solution was determined using inductively coupled plasma atomic emission spectroscopy (ICAP7000 plus series ICP–AES from Thermo Fisher Scientific, Waltham,

MA, USA), and specimens were periodically withdrawn from the test solution. Each test of 48 h was repeated three times to determine any data variation. After completing the test, the corrosion rates of each individual period and the average corrosion rates of the five individual periods were calculated.

After performing the corrosion test on the specimens, the characteristics of the oxide film formed on the surface of the Zr702 specimen surface were investigated. The morphological features of the oxide films were studied using scanning and transmission electron microscopy (SEM and TEM) with an image corrector. The TEM cross-sectional specimens were prepared using focused ion beam (FIB) milling (FEI Helios Nano lab 460HP, Thermo Fisher Scientific, Waltham, MA, USA) along with lift-out and trench techniques. The compositions and thicknesses of the oxide layers in the specimens were studied using scanning transmission electron microscopy (STEM). X-ray photoelectron spectroscopy (XPS, Escalab250X, Thermo Fisher Scientific, Waltham, MA, USA) and X-ray diffraction (XRD) were used to gain an enhanced understanding of the surface structures of the specimens. HAADF-STEM observations of the Zr702 specimens made after undergoing corrosion testing were made using a probe-aberration-corrected FEI STEM (Thermo Fisher Scientific, Waltham, MA, USA) at 300 kV. Energy-dispersive X-ray (EDX) mapping was performed using a Cs-corrected JEM ARM200F STEM (JEOL Japan Electronics Co., Ltd, Tokyo, Japan). The STEM images and EDX mapping data were obtained for several regions in the specimens. As the data obtained for different regions were consistent, only the representative data are presented here.

3. Results

3.1. Surface Morphology and Composition of the Oxide Film

Figure 1 shows the typical SEM images of the Zr702 specimen surfaces after undergoing 240 h of corrosion testing in boiling 6 M nitric acid and fluorinated nitric acid. Figure 1a shows the morphology of a Zr702 specimen immersed in 6 M HNO₃ solutions, showing clearly visible, surface scratches and defects caused by mechanical polishing. Figure 1c–e reveal that the corrosion morphologies of the specimens in the 50, 100, and 200 ppm NaF solutions are completely different from those of the specimens in the 0 and 10 ppm NaF solutions. Corrosion pits, the typical corrosion morphology feature of Zr in solution containing F[−], could be seen only in the specimen immersed in the 50 ppm NaF solution. Corrosion pits were the only corrosion phenomenon that could be seen in the overall morphology of each specimen. Furthermore, Figure 1c–e show that surface scratches and defects caused by mechanical polishing had disappeared during the corrosion process. Granular corrosion products could be observed on the specimen surfaces. As the NaF concentration was increased from 0 to 200 ppm, the particle size of the corrosion product increased. These corrosion morphology characteristics indicate that the Zr702 specimen in fluorinated nitric acid is uniformly corroded.

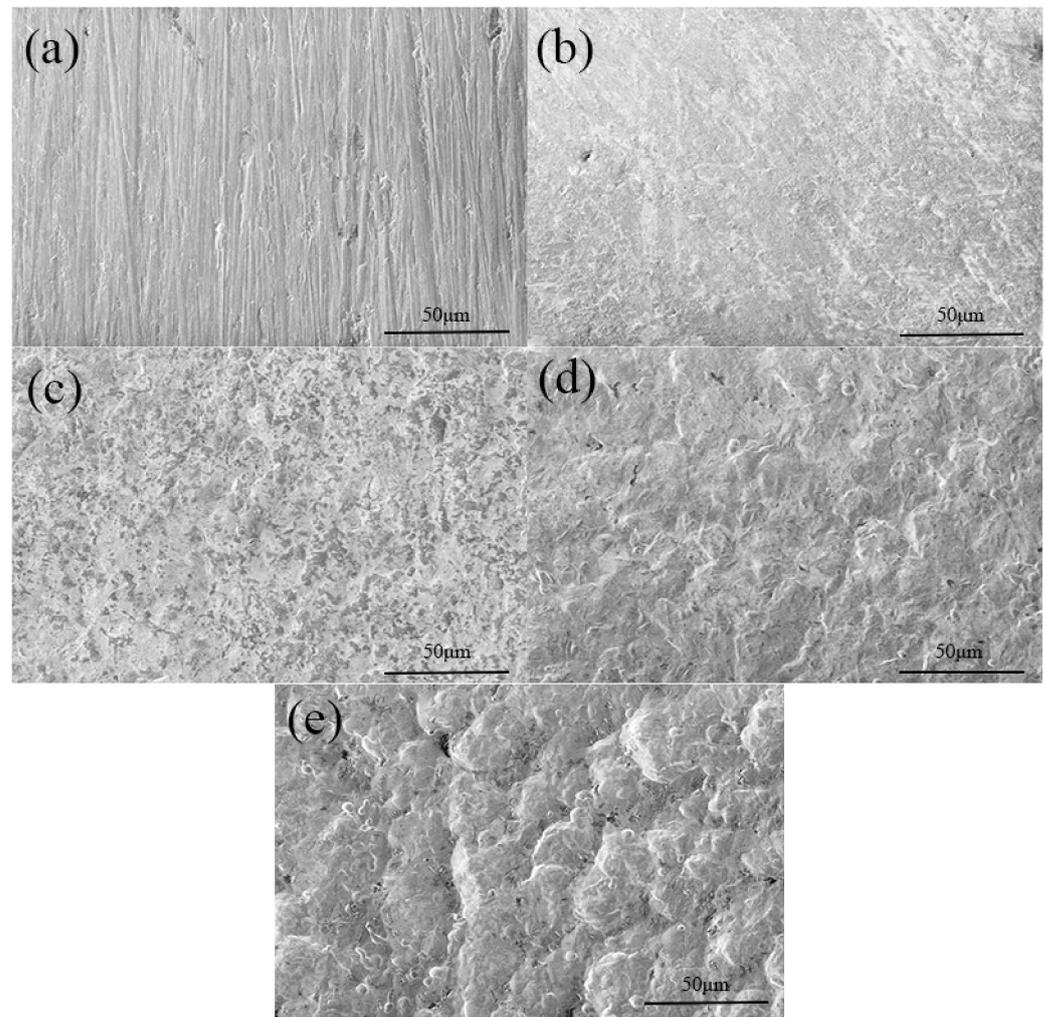


Figure 1. Typical SEM images of Zr702 specimens immersed in 6 M HNO₃ containing (a) 0 ppm; (b) 10 ppm; (c) 50 ppm; (d) 100 ppm; and (e) 200 ppm NaF.

The structural characteristics of the Zr702 specimens in 6 M HNO₃ containing NaF after the specimens were subjected to corrosion tests are illustrated in Figure 2. According to the JCPDS PDF05-0665 card, the diffraction peaks at $2\theta = 34.9^\circ$, 36.5° , 47.99° , 63.54° , 73.45° , and 82.44° corresponding to the (002), (101), (102), (103), (004), and (104) planes, of Zr, respectively. According to the JCPDS PDF49-1746 card, the diffraction peaks at $2\theta = 54.4^\circ$, 57.1° , and 64.6° correspond to the m-ZrO₂ (002), (040), and (122) planes of monoclinic zirconium oxide (m-ZrO₂), respectively [11]. It has been observed that ZrO₂ mostly comprises m-ZrO₂. The diffraction peaks at $2\theta = 32.0^\circ$ correspond to the (012) plane of HfO₂ according to PDF 40-1173. The diffraction peaks at $2\theta = 32.4^\circ$ and 37.6° correspond to the (230) and (041) planes of Zr (F, O)_{3.6} according to PDF40-1096. The XRD patterns of specimens without any F⁻ and with 10 ppm F⁻ show diffraction peaks of α -Zr along with a few HfO₂ phases. XRD diffraction patterns of specimens with 50 ppm F⁻, 100 ppm, and 200 ppm F⁻ show diffraction peaks of α -Zr, m-ZrO₂, and Zr (F, O)_{3.6}. (Figure 2). With an increase in F⁻ concentration, the corrosion products on the ZrO₂ specimen surfaces change from HfO₂ to a mixture of ZrO₂ and Zr (F, O)_{3.6}, and the diffraction peak of the corrosion products becomes stronger and stronger, while the diffraction peak of Zr becomes weaker. Furthermore, several previous researchers had observed two ZrO₂ structures, namely, m-ZrO₂ and t-ZrO₂, when the Zr and Zr alloy were immersed in boiling nitric acid, with m-ZrO₂, more stable than t-ZrO₂, as the dominant compound [20–24]. However, t-ZrO₂ was not detected in this study.

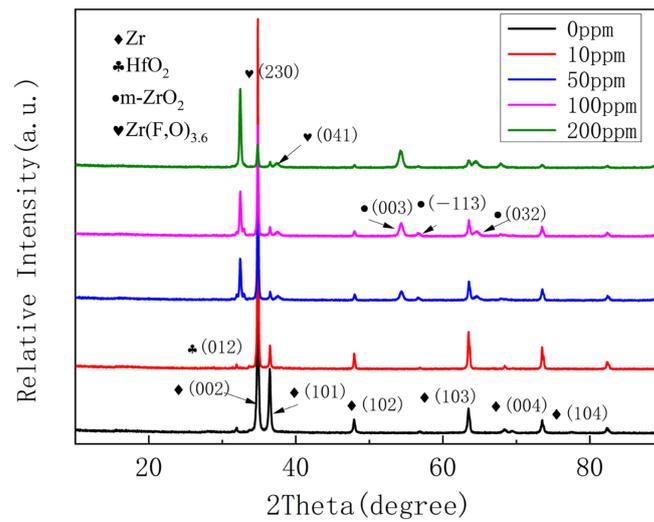


Figure 2. XRD pattern of the Zr702 sample impregnated in 6 M HNO₃ containing different fluoride ion concentrations.

Figure 3 shows the HAADF-STEM image of the specimens immersed in a boiling 6 M HNO₃ solution with an F-concentration of 10 ppm subjected to corrosion for 240 h and the corresponding EDX maps of O, Zr, and Hf. Figure 3A shows the HAADF-STEM image, while Figure 3B–D show the EDX analytical maps of O, Zr, and Hf. Figure 4e shows the EDX line scan profiles of the three elements O, Zr, and Hf. The corroded oxide layer comprised an outermost layer of HfO₂ and a sub-outer layer of ZrO₂.

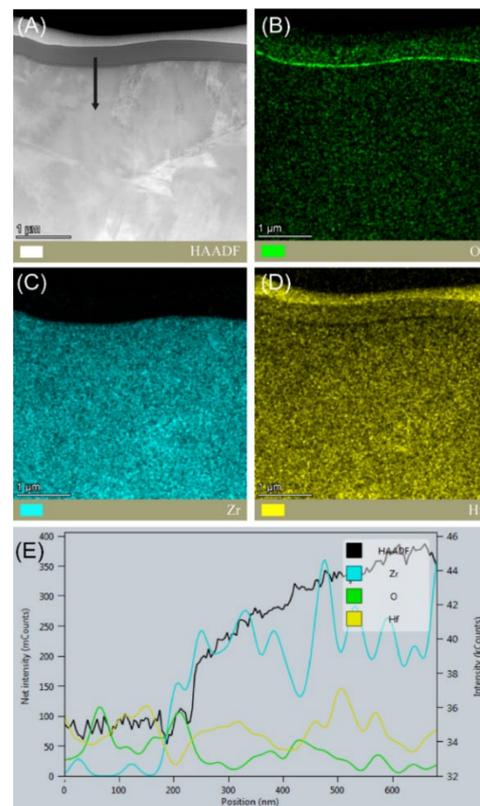


Figure 3. (A) HAADF-STEM image of a corroded specimen immersed for 240 h in a boiling 6 M HNO₃ solution with an F-concentration of 10 ppm, and EDX mapping of (B) O, (C) Zr and (D) Hf. (E) the EDX line scan profiles of O, Zr, and Hf.

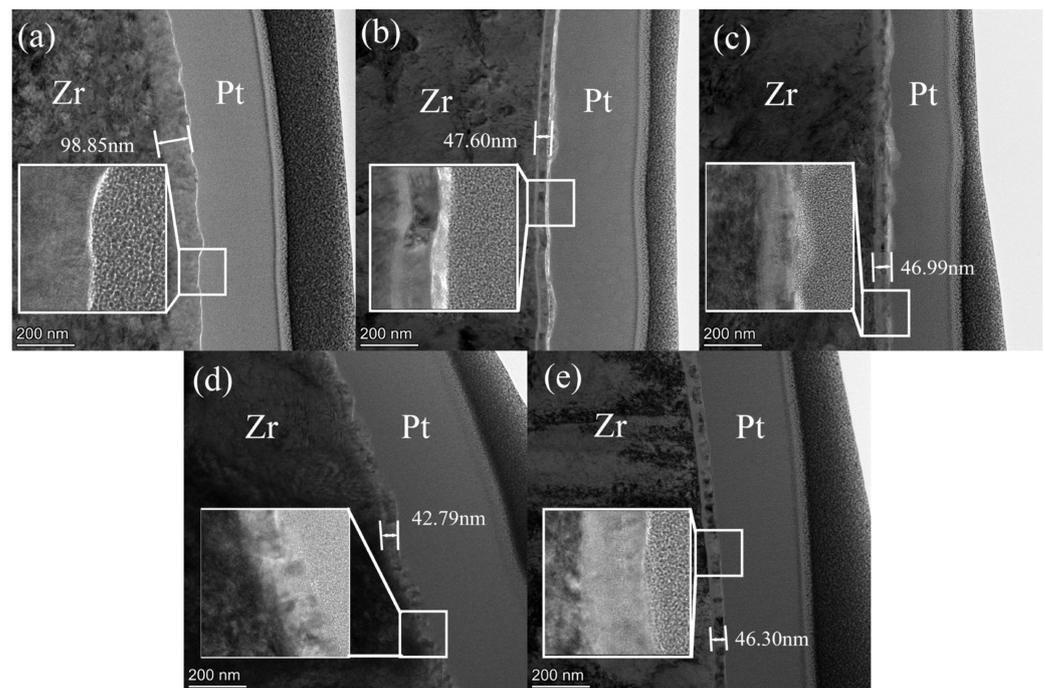


Figure 4. TEM characterization of the oxide films formed on the specimens' surfaces after being subjected to 240 h of corrosion in boiling 6 M HNO₃ with F⁻ concentrations of (a) 0 ppm, (b) 10 ppm, (c) 50 ppm, (d) 100 ppm and (e) 200 ppm.

Figure 4a–e show the representative cross-sectional TEM images of the oxide films on the specimen surfaces after being subjected to 240 h of corrosion in boiling 6 M HNO₃ and fluorinated nitric acid with different F⁻ concentrations. The oxide film formed between Zr702 and platinum was homogeneously distributed. As shown in Figure 4a, ~98.85 nm thick oxide layer is present in the specimen immersed in the F⁻ free HNO₃ solution. The oxide layers of the specimens in HNO₃ solution with 10, 50, 100, and 200 ppm F⁻ concentrations shown in Figure 4b–e, respectively, are 42–48 nm in thickness, and thus they are much thinner than the oxide layer formed in the specimen immersed in the F⁻ free HNO₃ solution. The HfO₂ layers, as shown in Figure 4a,b (white edge position) on Zr702 in 0 ppm and 10 ppm test samples after 240 h of the immersion test were 6 nm and 15 nm, respectively, and the HfO₂ layer was uniform and continuous, which had a good protective effect for the HNO₃ solutions. However, the HfO₂ layer in the 50, 100 and 200 ppm test samples, after 240 h of the immersion test, began to be discontinuous due to partial dissolution, as the enlarged images of the oxide film show. At 10 ppm, a continuous hafnium oxide film can be seen to protect Zr702. At 50 ppm, the film begins to dissolve and become discontinuous. When the concentration increases to 100 ppm, the boundary is blurred, the corrosion is intensified, the ion channel is formed, and the zirconia film begins to corrode. At 200 ppm, the oxide film almost disappears and completely dissolves. These TEM observations confirm that the oxide film thickness decreased as the F⁻ content in the HNO₃ solution increased.

3.2. Microstructure of the Oxide Film

To further investigate the chemical states of the films formed on the surfaces of the Zr702 specimens after they were exposed to corrosion for 240 h, high-resolution XPS spectra shown in Figure 5 were obtained. In Figure 5a, 50 ppm peaks in fluorinated nitric acid at 183.0 and 185.3 eV were assigned to the Zr⁴⁺ 3d_{3/2} and Zr⁴⁺ 3d_{5/2} electrons in ZrO₂ and ZrF₄ [25–27]. The 0 ppm peaks in fluoride-free nitric acid at 185.9 and 183.5 eV originate from ZrO₂, which is in line with the values provided by J. Jayaraj [7]. The peaks at 10 ppm, 100 ppm, and 200 ppm in the spectrum of fluorinated nitric acid are ascribed to ZrF₄ and

ZrO₂. In Figure 5b, a peak of Hf 4f is present in all five samples; the peaks obtained at 17.8 and 22.8 eV correspond to the Hf 4+ 4f 3/2 electrons in HfO₂ and Hf 4+ 4f 3/2 electrons in HfF₄, respectively [28,29]. Furthermore, as can be seen in Figure 5c, the 50 ppm peaks in fluorinated nitric acid at 531.4 eV are ascribed to O1s in ZrO₂. The peaks of 50 ppm in fluorinated nitric acid at 530.4 eV were assigned to the O1s electrons in HfO₂. In Figure 5d, the 10-ppm peak in the fluorinated nitric acid at 686.2 eV was assigned to the F1s electrons, which proved the bond between F–Zr and F–Hf, indicating the presence of ZrF₄ [7,30,31] and HfF₄. However, the F1s peak is not present in the other four specimens. Thus, it can be concluded that Zr forms a normal ZrO₂ passive film when immersed in nitric acid solutions, whereas in solutions containing NaF, the corrosion product ZrF₄ film replaces ZrO₂. The incorporation of F[−] ions into the oxide film and the presence of ZrF₄ and HfF₄ indicate that the fluoride ions are responsible for the dissolution of the oxide film of Zr702 when exposed to fluorinated nitric acid. Similar results were observed in the document [6].

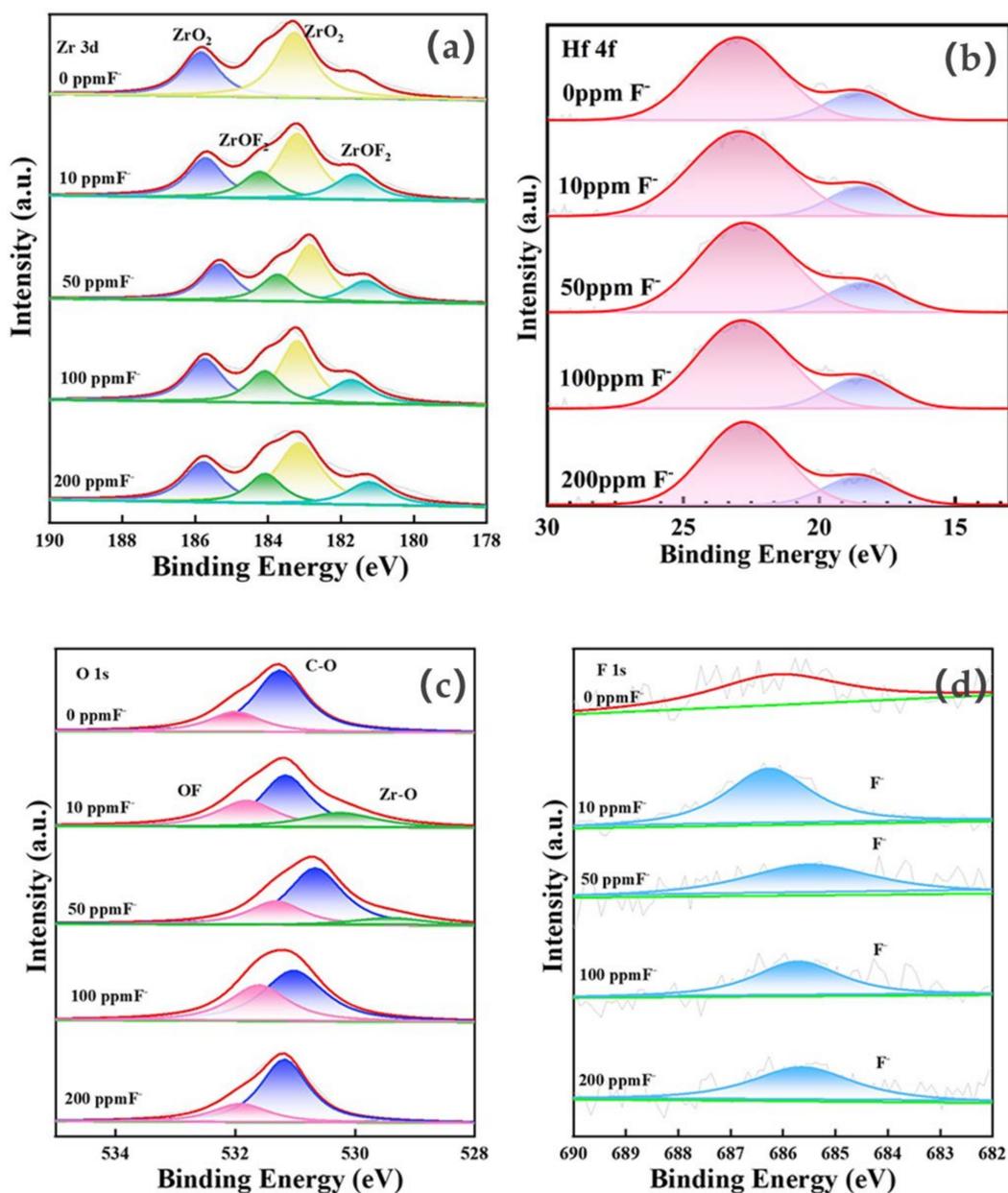


Figure 5. High resolution XPS spectra of the Zr702 specimens immersed in 6 M HNO₃ (a) Zr 3d; (b) Hf 4f; (c) O1s; and (d) F1s, after they were subjected to corrosion tests.

To further investigate the microstructures of the oxide films, these specimens were photographed with a subregional high-resolution phase, and the results are shown in Figures 6 and 7. Figure 6 shows the HRTEM images taken from three different zones of the oxide films of the specimens immersed in a HNO_3 solution with 200 ppm F^- for 240 h. As shown in Figure 6A, the oxide layer has a nanocrystalline cluster. Figure 7 shows the magnified view of the high-resolution phases shown in Figure 6. As shown in Figure 7(1-A~1-C), the outermost 1# region of the oxide layer corresponds to the (101), (012), and (111) crystal planes of HfO_2 , respectively. The Figure 7(2-A~2-D) in the 2# region correspond to the (120), (011), (200), and (210) crystal planes of ZrO_2 , respectively. The Figure 7(3-A~3-E) in the 3# region correspond to the (031) and (041) crystal planes of Zr (F, O) 3.6, and (210), (111), and (251) of crystal planes of ZrO_2 , respectively.

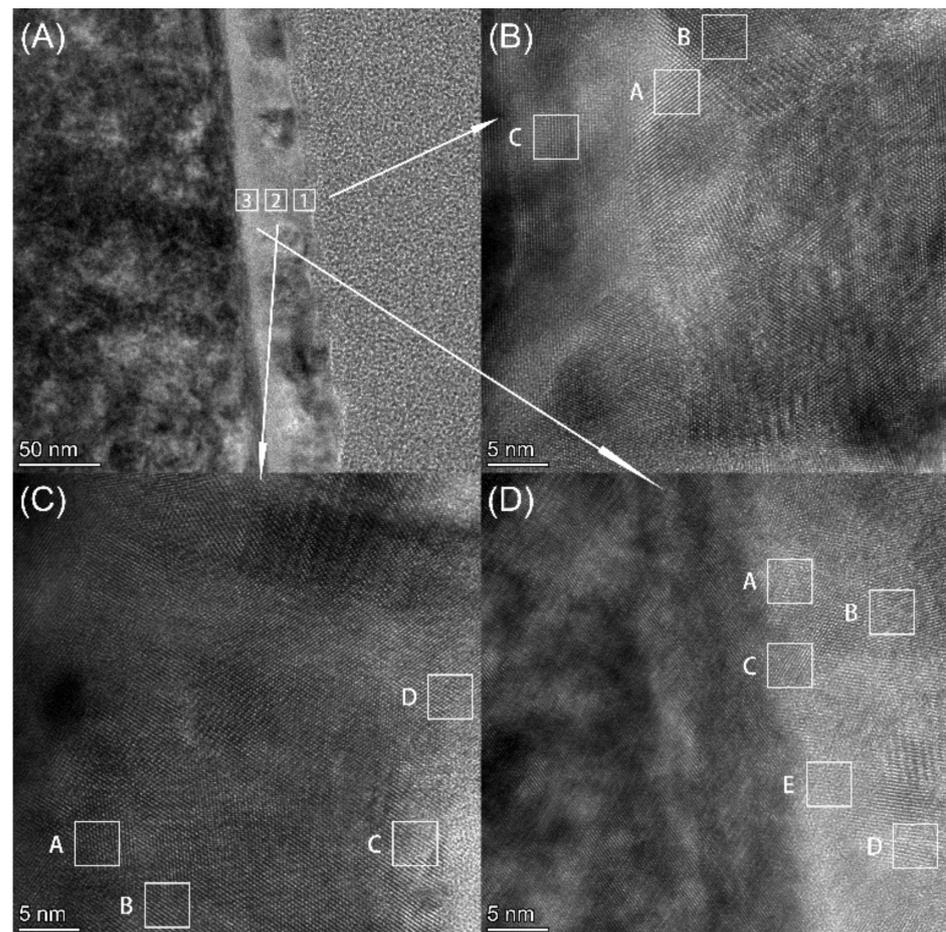


Figure 6. HRTEM images of three different zones in oxide films of the specimens immersed in HNO_3 solutions with 200 ppm F^- for 240 h (A) outer layer 1# zone, (B) middle layer 2# zone, and (C) inner layer 3# zone (D).

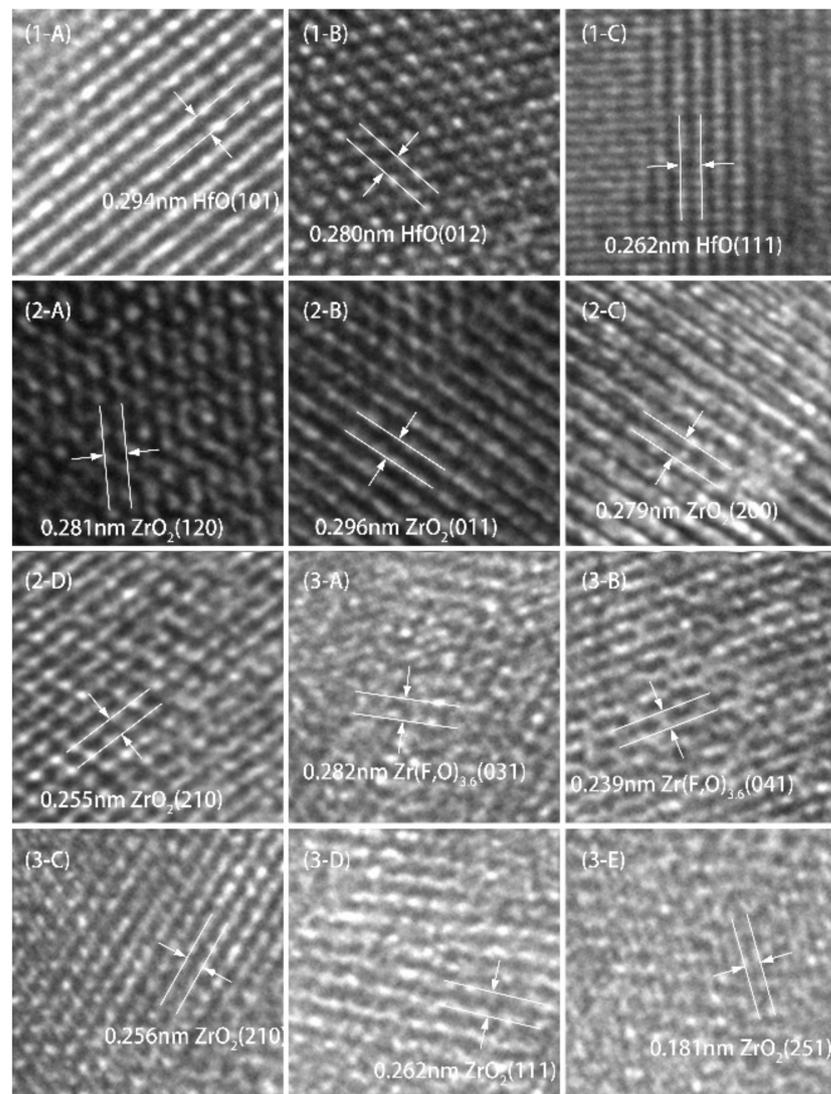


Figure 7. Enlarged view of the high-resolution phases shown in Figure 6. (1-A–1-C) are different areas in 1#, (2-A–2-D) are different areas in 2#, (3-A–3-E) are different areas in 3#.

3.3. Corrosion Behaviour of Zr702

The variation of the cumulative weight losses of the Zr702 specimens after they were immersed in boiling 6 M nitric acid solutions with different F^- concentrations for five separate immersion periods as a function of the immersion duration is shown in Figure 8. The maximum corrosion rate of all the Zr702 specimens occurred in the first period, while the minimum corrosion rate occurred in the last period, except for the specimen immersed in the F^- free solution. It is ascribed to the corrosion process, which was limited by fluorine diffusion and consumption. The corrosion rate of the Zr702 specimen immersed in the F^- free solution was close to zero for all five periods, which demonstrates that the Zr702 has an extremely high corrosion resistance at the boiling point of 6 M HNO_3 . However, after 240 h immersion in the solution, the total corrosion rate reduced and remained at a constant value of 56.92 mg/m^2 as the F^- in the solution increased to 200 ppm.

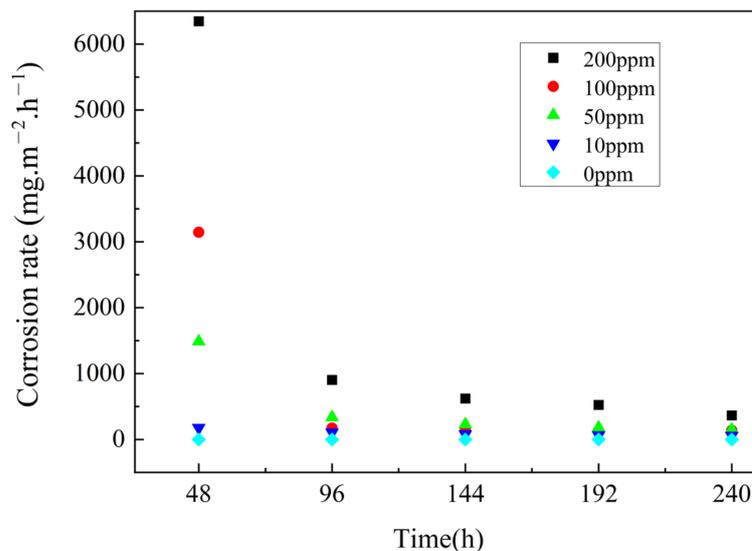


Figure 8. Corrosion rates (corrosion weight loss) versus exposure time for the Zr702 specimens during each of the five periods.

The presence of F^- ions significantly changed the nature of the oxide film and transformed the zirconium ions insoluble in the acid to complex zirconium ions soluble in the acid. The Zr^{4+} concentrations were obtained from the ZrO_2 film dissolved in the HNO_3 solution containing F^- , which was measured for five different periods. Table 1 shows the Zr^{4+} concentration in the HNO_3 test solution containing F^- ions for the five periods considered. As Table 1 shows, for all five periods, the Zr^{4+} concentration in the F^- free test HNO_3 solution was lower than that in the HNO_3 solution containing F^- , indicating that the higher the F^- ion concentration, the higher the number of zirconium ions dissolved in the HNO_3 solution.

Table 1. Zr^{4+} concentration in the HNO_3 solutions containing F^- ions for the five periods.

Time (h)	Zr^{4+} ($\mu g/mL$)	F-Concentration in HNO_3 (ppm)				
	0	10	50	100	200	
48	0.15	21.23	193	366.4	691.9	
96	0.23	34.14	237	375.9	780.4	
144	0.22	45.34	276	430.6	949.8	
192	0.49	52.16	284	415.1	927.9	
240	0.31	60.19	323.6	446.9	1046	

4. Discussion

Zr702, commercially pure zirconium, is the material mostly used in corrosion-resistant applications. The hafnium oxide formation on the surface of Zr702 protected it from the HNO_3 solutions at all concentrations, which had a good protective effect in the F-free HNO_3 solution. However, the external HfO_2 layer in fluorinated nitric acid after 240 h of immersion became discontinuous due to partial dissolution, and the erosion protection against F^- became weaker. This is attributed to the destruction of the integrity of the HfO_2 layer, which enables the fluoride ions to diffuse more easily and leads to a higher population of structural defects in the oxide film and an increase in the rate of the dissolution process of Zr702.

The binding ability of Hf and O is higher than that of Zr, so to resist the corrosion of fluoride ions, Hf preferentially binds to the oxygen first formed in the HfO_2 in the top-most layer on the oxide film; this result is consistent with a thicker hafnium oxide layer on the surface of a corroded sample with 10 ppm than 0 ppm F ions. Hafnium oxide is more

resistant to fluoride ions than zirconia. Although the slow dissolution of the oxide film led to a decrease in the protection it provided against corrosion, Zr702 continued to resist corrosion. Therefore, increasing the hafnium content in the alloy can improve the resistance to fluoride ions.

The incorporation of F-ions electrolytically into the oxide film (the presence of ZrF_4 , HfF_4 and $Zr(F, O)_{3.6}$) indicated that the fluoride ions are responsible for the dissolution of the oxide film of Zr702. As the F^- concentration increased, the HfO_2 layers' protection against F^- became weaker, the faster the diffusion rate of the fluoride ions from the high concentration region outside the oxide film to the low F^- concentration region within the oxide film, forming a soluble $Zr(F, O)_{3.6}$ compound. The oxide layer started to dissolve as it was generated. The dissolution of the oxide layer was limited by fluorine diffusion and consumption with time extension; the present result is in agreement with that of the maximum corrosion rate of the Zr702 specimens in fluorinated nitric acid occurred in the first period, while the minimum corrosion rate occurred in the last period.

5. Conclusions

The effect of fluoride ions on oxide formation and dissolution behaviors in Zr702 was investigated in boiling 6 M nitric acid solutions with different F-concentrations. The cumulative weight losses of the Zr702 specimens after they were immersed in fluorinated nitric acid were several orders larger than the value in fluoride-free nitric acid. The conclusions are listed below:

1. The thickness of the oxide films formed on Zr702 immersed in fluorinated nitric acid solution was between 42–48 nm, which is much thinner than that of the oxide layer (~98.85 nm thickness) in the F^- free HNO_3 solution. Therefore, an increase in F^- ions concentration restricts the oxide film growth and increases the average rate of dissolution of the oxide layer.
2. When the concentration of fluoride ions changes from 0 ppm to 200 ppm, the corrosion rate at the concentration of fluorine ions at 0 ppm and 10 ppm basically remains unchanged within five time periods, while the corrosion rate at 50 ppm to 200 ppm shows a downward trend with the increase of time. The most obvious change is at 48 h when the concentration of fluoride ions increases, the higher the corrosion rate.
3. The oxide film was identified to be a nanocrystalline cluster in a fluorinated nitric acid solution. The oxide films comprised outermost HfO_2 and HfF_4 layers, sub-outer ZrO_2 and ZrF_4 layers, and an innermost $Zr(F, O)_{3.6}$ layer. From the distribution of the oxide film, it can be seen that in the F^- -containing boiling nitric acid solution, Hf in the alloy of Zr702 metal will migrate from the inside to the surface to form oxides and fluoride preferentially than Zr, which can play a protective role in Zr702. With the increase of fluorine ion concentration, it will penetrate the oxide film, indicating that fluorine ions have a dissolution effect on the Zr702 oxide film.

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Conflicts of Interest: Author Hangbiao Su was employed by the company Xi'an QinTi Intelligent Manufacturing Technologies Co., Ltd. Author Jianping Xu was employed by the company Xi'an Rare Metal Materials Institute Co., Ltd. The remaining authors declare that the research was conducted in the absence of any commercial or financial relationships that could be construed as a potential conflict of interest.

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